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Subject: Chemistry

Class: Semester-4

Paper: C9T: Inorganic Chemistry

Topic: Chemistry of p Block elements

Part 2

Comments- Study the whole lesson thoroughly.

[N.B. - Acknowledgement of indebtedness to Mr.Sibshankar Das, my respected Teacher regarding collection of study materials in Inorganic Chemistry]

They remain unaffected by most of the chemical reagents such as weak acids, alkalis and salt solutions i.e., silicones are chemically inert.

iii) They are water repellent (जलप्रतिकर्षी) i.e., they are not wetted and are used in making water proof cloth and paper.

iv) All silicones have good insulating properties. Due to these properties they are used as insulating materials for electric motors and other electric substances/instruments.

v) They are non-toxic.

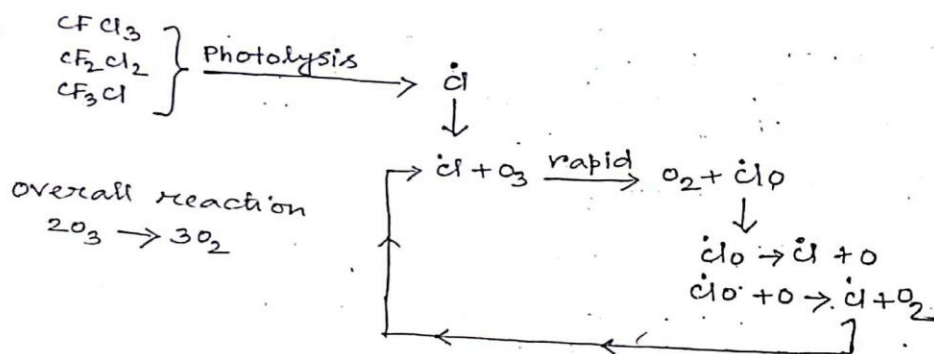
*** Freons (C.F.C) [chloro fluoro carbon]

Mixed chloro fluoro carbons such as CFCl_3 , CF_2Cl_2 , CF_3Cl are known as freons. They are unreactive and non-toxic and are widely used as refrigeration fluids and for washing computer boards etc. Despite being inert they cause environmental damage.

Freons are very much more effective green house gases in the atmosphere than CO_2 , though the amount of freons present is extremely small. Much more seriously the freons have penetrated the upper atmosphere and are causing damage to the ozone layer. A hole in the ozone layer has appeared over the south pole and a similar hole seems to be developing over the north pole. The ozone layer is important as it filters the radiation from the sun and prevents most of the harmful UV radiation from reaching the earth. Excessive exposure to UV radiation should be avoided as it causes skin-cancer in humans.

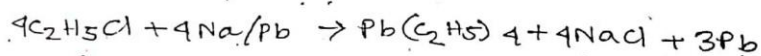
In the upper atmosphere freons undergo a photolytic reaction and produce free chlorine atoms, (radicals). These react readily with ozone. The Cl radicals from decomposed slowly.

reforming Cl radicals, which react with more ozone and so on. There is no effective sink for Cl radicals. Once formed, they are used again and again. So a small number of radicals make a very effective scavenger (transfer) for ozone.



Q: Tetra-ethyl lead:

Tetra-ethyl ~~lead~~ ^{lead} is commercially the most important organo ~~lead~~ ^{lead} compound. It can be made by the action of ethyl halides on sodium ~~lead~~ ^{lead} alloy. Actually it is made by the action of ethyl chloride on an alloy of ~~lead~~ ^{lead} with 10% Na. Pyridine being used as a catalyst. A temperature of 40-60°C is usually maintained.



NaCl and excess Na are removed by washing with water and tetra-ethyl ~~lead~~ ^{lead} is prepared by steam distillation.

It is insoluble and unaffected in H_2O . It is used as antiknock agents in petrol. A small percentage of tetra-ethyl ~~lead~~ ^{lead} in petrol can prevent knocking in internal combustion engines, whereby it is possible to have a higher compression in the cylinders and hence a higher efficiency. About 2-3 ml of $\text{Pb}(\text{C}_2\text{H}_5)_4$ is used per gallon of petrol. It decomposes to produce ethyl radicals.

$\text{Pb}(\text{C}_2\text{H}_5)_4 \rightarrow \text{Pb} + 4\text{C}_2\text{H}_5\cdot$
 These ethyl radicals prevent explosive combustion responsible for knocking.

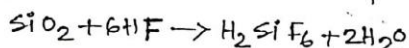
Pb is poisonous to man. During the burning of petrol lead from $Pb(C_2H_5)_2$ pollutes the atmosphere. ^{since the U.S.A. has} ~~divided Pb.~~ Particles released through the exhaust. ^{introduced lead free petrol to avoid pollution.}

Hydro. fluo. silicic Acid (H_2SiF_6) or Fluorosilicic acid:-

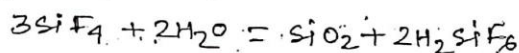
It is a complex halide of silicon in which 'Si' atom shows hexa covalency.

Preparation:-

(i) It is made in solution by dissolving SiO_2 in aqueous HF.

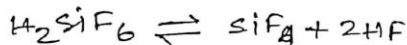


(ii) An aqueous solution of H_2SiF_6 is obtained by passing SiF_4 into H_2O :



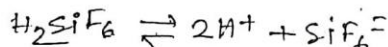
Properties:-

(i) The anhydrous acid is unknown. on concentrating an aqueous solution, the acid decomposes to SiF_4 and HF.

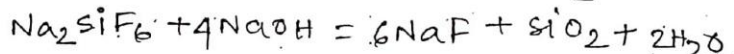
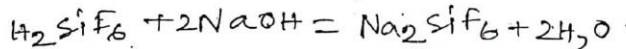


The mono, di, tri and tetra hydrates can be crystallised from the aqueous solution.

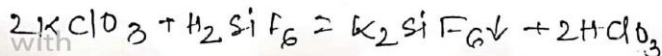
(ii) The pure acid does not ^{corrode} ~~corrode~~ glass, but it decomposes liberating HF, which ^{in evaporat} attacks glass or porcelain. $(H_2SiF_6 \rightleftharpoons SiF_4 + 2HF)$ It is a strong acid and it is highly ionised in solution as is H_2SO_4 .



(iii) It reacts with alkalis, forming fluo. silicates which are decomposed by excess of alkali.



(iv) When H_2SiF_6 reacts with $KClO_3$, $HClO_3$ is obtained.



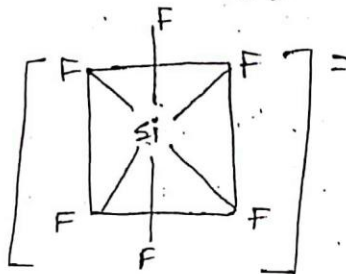
Uses:-

This acid is used -

- (i) As an antiseptic in medicines.
- (ii) For estimating potassium.
- (iii) For testing Ba-salts.
- (iv) For the preparation of HClO_3 etc.

Structure:-

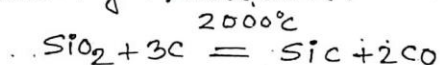
The fluo silicate ion (SiF_6^{2-}) is perfectly octahedral.

Silicon carbide (SiC) / Carborundum

Silicon carbide is a covalent carbide.

Preparation:-

It is prepared by heating a mixture of coke and SiO_2 in an electric furnace at 2000°C by the following reaction.



A mixture of sand and crushed coke (5:3) with some common salt and sand dust is heated electrically to $1500-2200^\circ\text{C}$ by a carbon rod passing through the mass. The salt is used to make the mass fusible and the sand dust to make the mass porous. At this high temperature the above reaction occurs resulting in the formation of SiC.

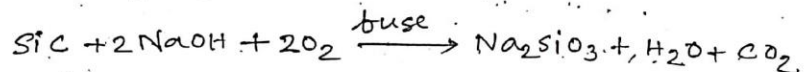
Properties (Physical):-

It is a colorless crystalline solid in pure form. The commercial sample is yellow, green or blue. It is nearly as hard as diamond. It is insoluble in H_2O and alcohol.

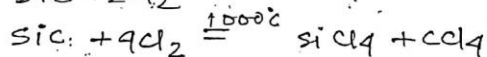
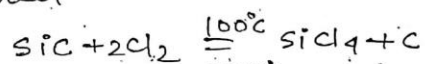
i) chemically, SiC is extremely inert and even at high temperature it is not attacked by HF, HCl, O₂ or S. Even a mixture of burning HNO₃ and HF has no action on SiC.

ii) It is slightly oxidised by air at about 1000°C. Silica formed during oxidation forms a protective layer on the surface of SiC. This layer of SiO₂ stops further oxidation of SiC.

iii) It reacts with molten NaOH, in presence of O₂ to form Na₂SiO₃.



iv) when SiC reacts with Cl₂, SiCl₄ and CCl₄ are obtained.



Uses :-

i) Due to its extreme hardness, it is used as an abrasive for cutting and grinding glasses.

ii) It is used in atomic reactor, since it serves as an excellent container for fuel at high temperatures.

iii) It has very high thermal and chemical stability. It also has high thermal conductivity. Due to these properties, it is used as a refractory material for making crucibles, which are used for melting metals.

Structure :-

SiC has infinite three dimensional structure of silicon and carbon atom in which each 'C' atom is tetrahedrally surrounded by four Si atoms and each Si atom is surrounded tetrahedrally by four carbon atoms. A simplified partial structure of SiC is shown below -

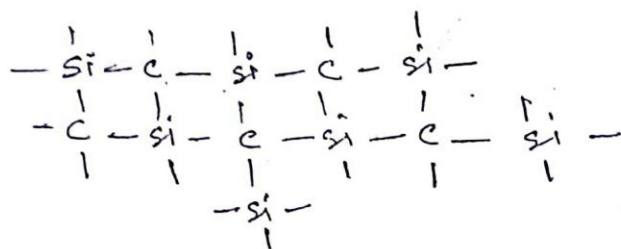


Fig: Partial structure of SiC .

9. Catenation of the elements of group IVA : (14)

All the elements of group IVA have a tendency to link with each other and thus form long chains of identical atoms ($M-M$ chains, M = element). Such long chains of identical atoms are called homochains. This type of linking of identical atoms with each other is called catenation or self-linkage.

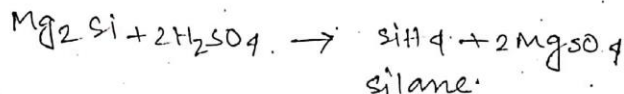
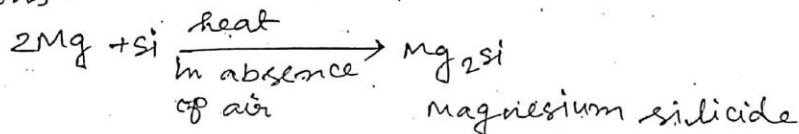
The tendency of an element (M) towards catenation is related with the magnitude of $M-M$ bond energy. Greater is the magnitude of $M-M$ bond energy, greater will be the tendency of M atom to show the property of catenation. Thus since the ^{values} bond energies decrease from $C \rightarrow Si \rightarrow Ge \rightarrow Sn \rightarrow Pb$, C atom shows maximum tendency for catenation. C atom by unity with other C atom can form long $C-C$ chains of any length. These chains may be straight chains, branch chains and cyclic chains. $C-C$ bonds are highly stable in the compounds ~~are~~ containing $C-C$ long chains. The property of catenation show by other elements of this group decreases as ~~the~~ moving down the group from C to Pb . ~~It is~~ due to maximum property of catenation of C atom that it is easy to prepare compounds containing $C-C$ chains upto twenty C atoms, while for silicon and Germanium, ~~it~~ it not possible. The silicon and germanium

compounds containing six or more atoms can be prepared. For 'Sn' and 'Pb' it is not possible. The compounds containing two units of 'Sn' and 'Pb' can be prepared.

Hydrides of Group IVA elements:-

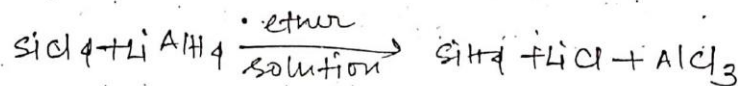
All the elements form volatile covalent hydrides, the ease of formation decreases down the group. Due to the strong tendency of catenation carbon forms a vast no. of chain and ring compounds including the alkanes (C_nH_{2n+2}), alkenes (C_nH_{2n}), alkynes (C_nH_{2n-2}) and many aromatic compounds.

Silicon forms a few saturated hydrides (Si_nH_{2n+2}) called silanes, analogous to alkanes. Silanes prepared in a mixture by the following reactions.

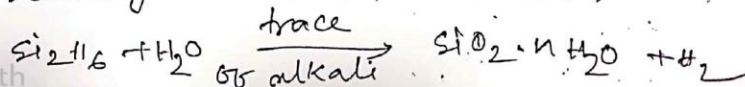


SiH_4 is purified by fractional distillation.

Pure mono silane has been prepared by reducing $SiCl_4$ with $LiAlH_4$.

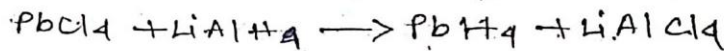
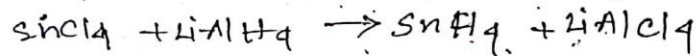


The silanes are much more reactive than alkanes. The silanes are strong reducing agent, ignites (C_5H_8 or CH_4) in air and explode in chlorine, hydrolysed readily in alkaline solution.



Several germanium hydrides (germanes) are known with formula GeH_{2n+2} upto $n=5$, they are similar to silane but less volatile, less reactive, less inflammable and are unaffected by water.

Stannane is much less stable. SnH_4 is known and is even less stable. SnH_4 and PbH_4 are difficult to prepared and are obtained by the action of LiAlH_4 on tetrahalides.



Q. SiH_4 has a higher boiling point than CH_4 while the boiling point of SiCl_4 is lower than CCl_4 - Explain.

'C' and 'Si' are the group IV A elements of the periodic table. The tetrahydride of 'C' is CH_4 and tetrahydride of 'Si' is SiH_4 . The molecular weight of SiH_4 is higher than the molecular weight of CH_4 . We know that the molecular weight is directly proportional to the intermolecular forces (vander waals force) among the molecules. Hence the intermolecular forces among the SiH_4 molecules are greater than CH_4 molecules. That is why SiH_4 has higher boiling point than CH_4 .

The tetrahalide of carbon is CCl_4 and the tetrahalide of silicon is SiCl_4 . SiCl_4 has higher molecular weight than CCl_4 . Hence SiCl_4 should have higher boiling point than CCl_4 . But actually the boiling point of SiCl_4 is lower than that of CCl_4 .

This anomaly (असामान्यता) has been explained on the assumption of multiple bonding between vacant d orbital of silicon and filled p orbital of Cl , so that there is an effective decrease in the inter molecular van der Waals' forces in $SiCl_4$ halides compare to that in carbon halides.

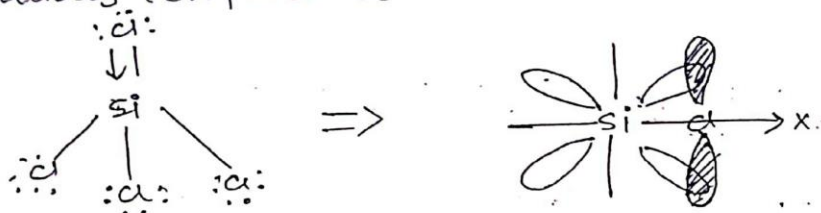
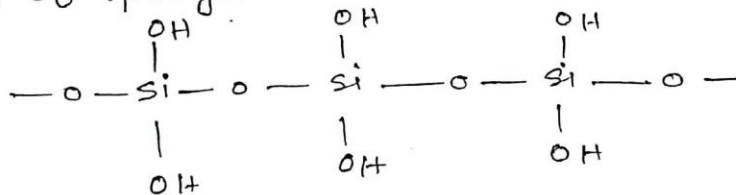


Fig: bonding in $SiCl_4$ showing overlap of a vacant silicon d -orbital (d_{xy}) with a filled Cl p orbital (p_y)

Silica gel: (amorphous silica, $SiO_2 \cdot nH_2O$) :-

Silica gel is a completely dehydrated silicic acid containing about 4% moisture. When a concentrated sodium silicate solution is acidified, a gel of polymeric silicic acid molecules results.



The gel contains much water held in the cage like structure of the polysilicic acid molecules. On heating in vacuum at $300^\circ C$, the water is driven off and the polysilicic acid itself dehydrates and converts to a hard transparent material. It is broken up, washed and dried. The end product is called silica gel.

Silica gel is a substance with a very large surface area and is used —